

SUPPORTING INFORMATION

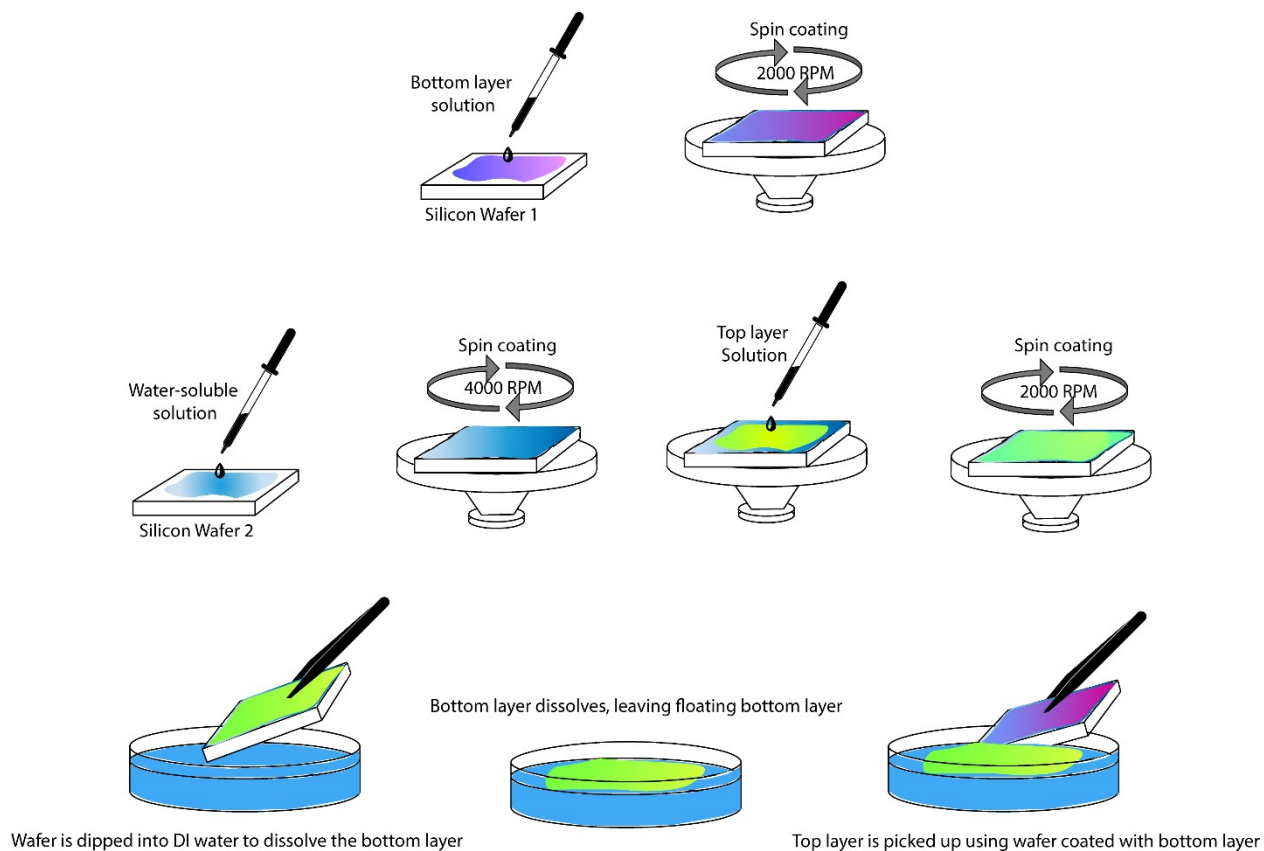
# Understanding and Controlling the Depth Sensitivity of Infrared Imaging and Nanospectroscopy for Bilayer Polymeric Thin Films

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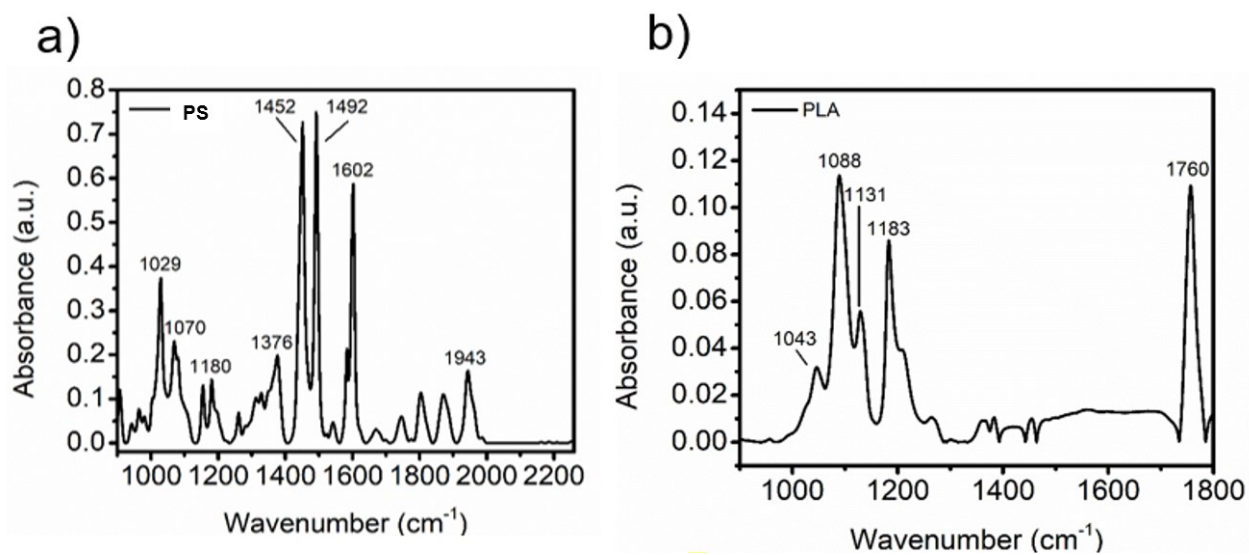
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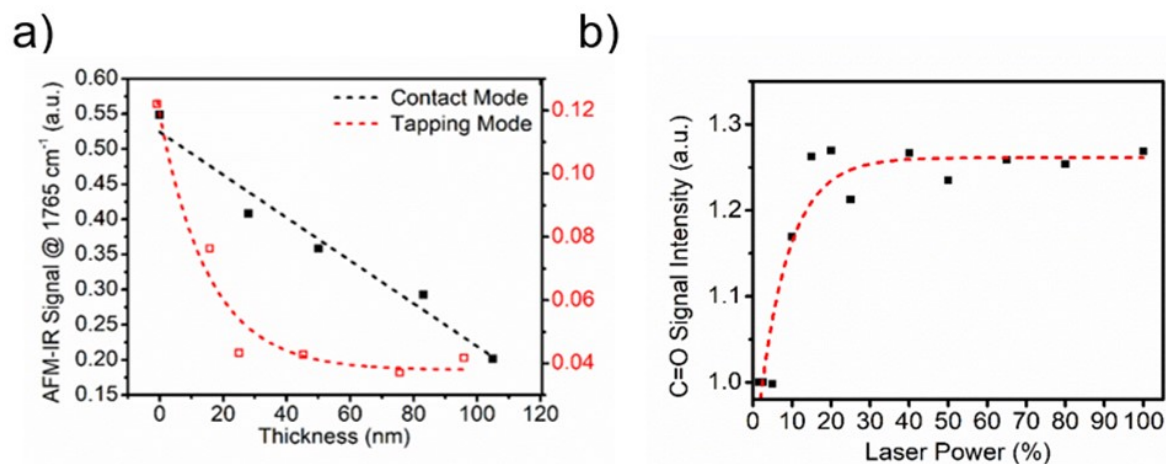
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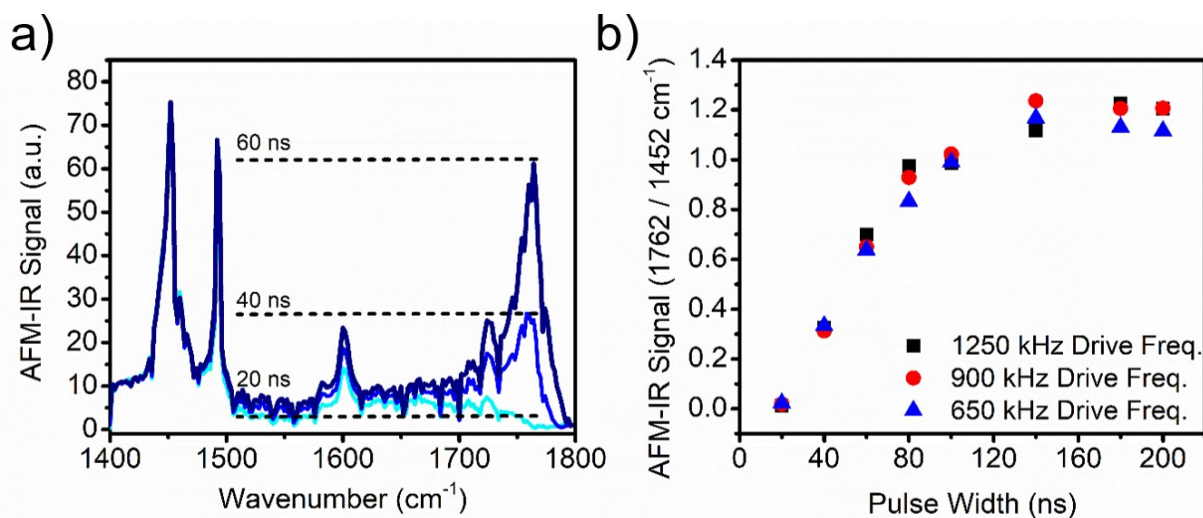
**Figure S1.** Complete sample preparation process for bilayer samples.



**Figure S2.** Bulk FTIR spectra of (a) PS and (b) PLA.



**Figure S3.** (a) Difference in AFM-IR signal acquired at 1765 cm<sup>-1</sup> using both contact mode and tapping mode. (b) AFM-IR signal intensity at 1765 cm<sup>-1</sup> as a function of laser power used.



**Figure S4.** (a) AFM-IR spectra acquired on a PS/PLA bilayer sample using a 20, 40, and 60 ns pulse width. (b) The AFM-IR Signal ratio of the PLA/PS signal as a function of laser pulse width (acquired in tapping mode).